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	Application No.	Applicant(s)		
	10/700,516	YAMAZAKI ET AL.		
Notice of Allowability	Examiner	Art Unit		
	Stephen W. Smoot	2813		
The MAILING DATE of this communication appears on the cover sheet with the correspondence address All claims being allowable, PROSECUTION ON THE MERITS IS (OR REMAINS) CLOSED in this application. If not included herewith (or previously mailed), a Notice of Allowance (PTOL-85) or other appropriate communication will be mailed in due course. THIS NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RIGHTS. This application is subject to withdrawal from issue at the initiative of the Office or upon petition by the applicant. See 37 CFR 1.313 and MPEP 1308.				
1. X This communication is responsive to applicant's election filed on 05 October 2005 and amendment filed on 28 January 2005.				
2.  The allowed claim(s) is/are <u>1-10 and 17-30</u> .				
<ul> <li>3.</li></ul>				
4. A SUBSTITUTE OATH OR DECLARATION must be submitted. Note the attached EXAMINER'S AMENDMENT or NOTICE OF INFORMAL PATENT APPLICATION (PTO-152) which gives reason(s) why the oath or declaration is deficient.				
<ul> <li>5. CORRECTED DRAWINGS ( as "replacement sheets") must be submitted. <ul> <li>(a) including changes required by the Notice of Draftsperson's Patent Drawing Review ( PTO-948) attached</li> <li>1) hereto or 2) to Paper No./Mail Date</li> <li>(b) including changes required by the attached Examiner's Amendment / Comment or in the Office action of Paper No./Mail Date</li> <li>Identifying indicia such as the application number (see 37 CFR 1.84(c)) should be written on the drawings in the front (not the back) of each sheet. Replacement sheet(s) should be labeled as such in the header according to 37 CFR 1.121(d).</li> </ul> </li> <li>6. DEPOSIT OF and/or INFORMATION about the deposit of BIOLOGICAL MATERIAL must be submitted. Note the attached Examiner's comment regarding REQUIREMENT FOR THE DEPOSIT OF BIOLOGICAL MATERIAL.</li> </ul>				
Attachment(s)  1. ☑ Notice of References Cited (PTO-892)  2. ☐ Notice of Draftperson's Patent Drawing Review (PTO-948)  3. ☑ Information Disclosure Statements (PTO-1449 or PTO/SB/0 Paper No./Mail Date 7-26-04; 12-30-04; 1-26-05; 1-10-4. ☐ Examiner's Comment Regarding Requirement for Deposit of Biological Material	6.	te ment/Comment ent of Reasons for Allowance Stephen W. Smoot Patent Examiner		
Stephen	W. Smoot	Art Unit 2813		

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This Office action is in response to applicant's election filed on 05 October 2005

and to applicant's amendment filed on 28 January 2005.

**EXAMINER'S AMENDMENT** 

1. An examiner's amendment to the record appears below. Should the changes

and/or additions be unacceptable to applicant, an amendment may be filed as provided

by 37 CFR 1.312. To ensure consideration of such an amendment, it MUST be

submitted no later than the payment of the issue fee.

The application has been amended as follows:

In the Specification:

Change the Title of the Invention to --Method for Manufacturing a Semiconductor

Device that Includes Adding Noble Gas to a Semiconductor Film and then Irradiating

the Semiconductor Film with Laser Light in the Presence of a Magnetic Field--.

In the Claims:

Cancel claims 11-16.

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2. Applicant's election with traverse of Group II in the reply filed on 05 October 2005 is acknowledged. It is agreed that claims 1, 19 are generic and, accordingly, claims 1-10, 17-30 have been examined on the merits

- This application is in condition for allowance except for the presence of claims
  11-16 drawn to an invention non-elected without traverse in the reply filed on 28

  January 2005. Accordingly, claims 11-16 have been cancelled.
- 4. Claims 1-10,17-30 are allowed.
- 5. The following is an examiner's statement of reasons for allowance:
  - Claims 1-10, 17-18 are allowed because the prior art of record does not teach or suggest, in combination with the other claim limitations, a method for manufacturing a semiconductor device that includes the step of adding noble gas to a semiconductor film combined with the step of then irradiating first and second laser light to the semiconductor film, wherein a magnetic field is applied to the semiconductor film when the first and second laser light are irradiated; and
  - Claims 19-30 are allowed because the prior art of record does not teach or suggest, in combination with the other claim limitations, a method for manufacturing a semiconductor device that includes the step of irradiating first and second laser light to a semiconductor film added with noble gas, wherein a

magnetic field is applied to the semiconductor film when the first and second laser light are irradiated.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

- 6. The prior art made of record and not relied upon is considered pertinent to applicant's disclosure. Nakayama, Izawa et al., and Akiyama et al. teach methods for crystallizing semiconductor layers that feature irradiating with a laser while applying a magnetic field.
- Any inquiry concerning this communication or earlier communications from the examiner should be directed to Stephen W. Smoot whose telephone number is 571-272-1698. The examiner can normally be reached on M-F (8:00 am to 4:30 pm).

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Carl Whitehead, Jr. can be reached on 571-272-1702. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

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Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

SWS